

10/590663
IAP9 Rec'd PCT/PTO 25 AUG 2006

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q96644

Hideo KOBAYASHI

Appln. No.: National Stage of PCT/JP2004/002814

Confirmation No.: Not yet assigned

Group Art Unit: Not yet assigned

Filed: August 25, 2006

Examiner: Not yet assigned

For: METHOD OF MANUFACTURING PHOTOMASK BLANK

PRELIMINARY AMENDMENT

MAIL STOP AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Prior to examination, please amend the above-identified application as follows on the accompanying pages.

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